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(54) **SCANNING ELECTRON MICROSCOPE**

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CPC **H01J 37/18** (2013.01); **H01J 37/244** (2013.01); **H01J 37/28** (2013.01); **H01J 2237/164** (2013.01); **H01J 2237/188** (2013.01); **H01J 2237/2002** (2013.01); **H01J 2237/24445** (2013.01); **H01J 2237/2605** (2013.01)

(58) **Field of Classification Search**

USPC 250/306–307, 309, 310, 311, 313

See application file for complete search history.

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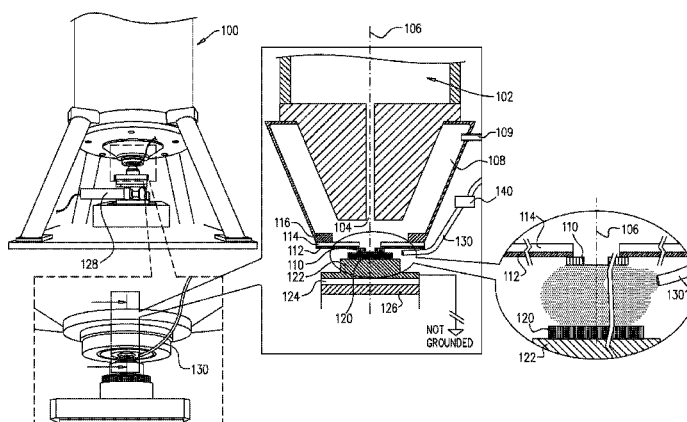
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ABSTRACT

A scanning electron microscope suitable for imaging samples in a non-vacuum environment, the scanning electron microscope including an electron source located within an enclosure maintained under vacuum, an electron permeable membrane disposed at an opening of the enclosure separating an environment within the enclosure which is maintained under vacuum and an environment outside the enclosure which is not maintained under vacuum, the electron permeable membrane not being electrically grounded and at least one non-grounded electrode operative as an electron detector.

19 Claims, 17 Drawing Sheets



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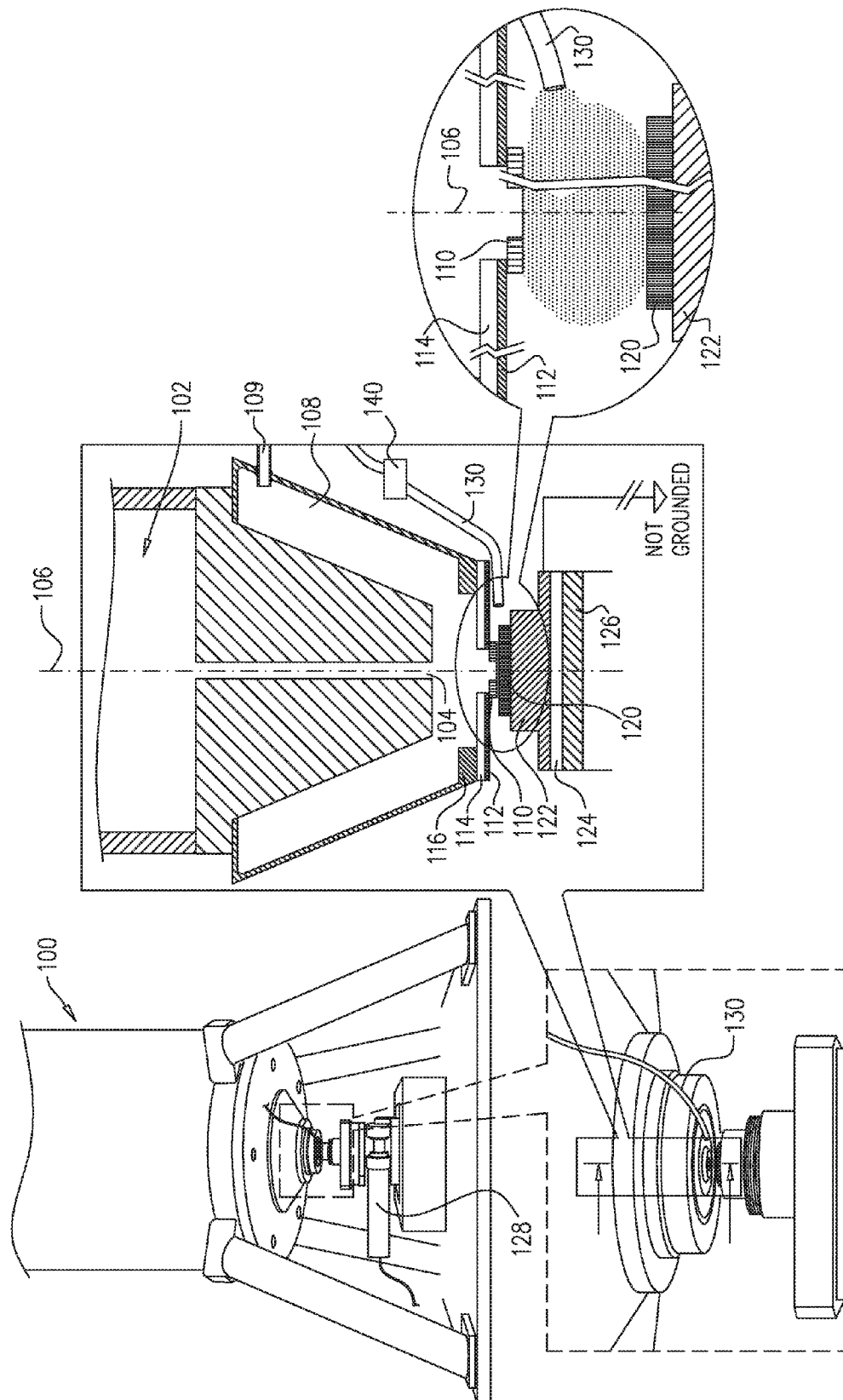
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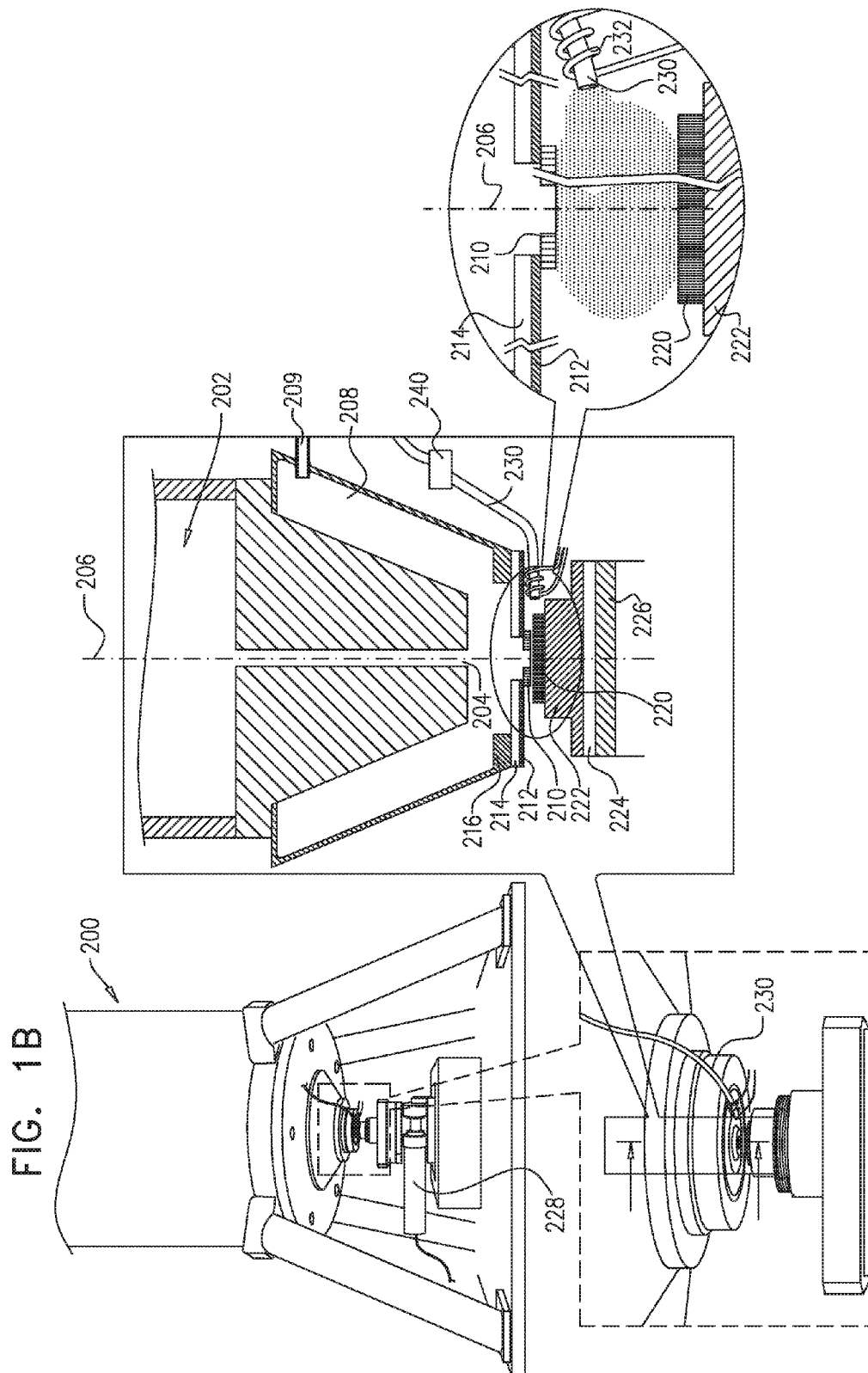
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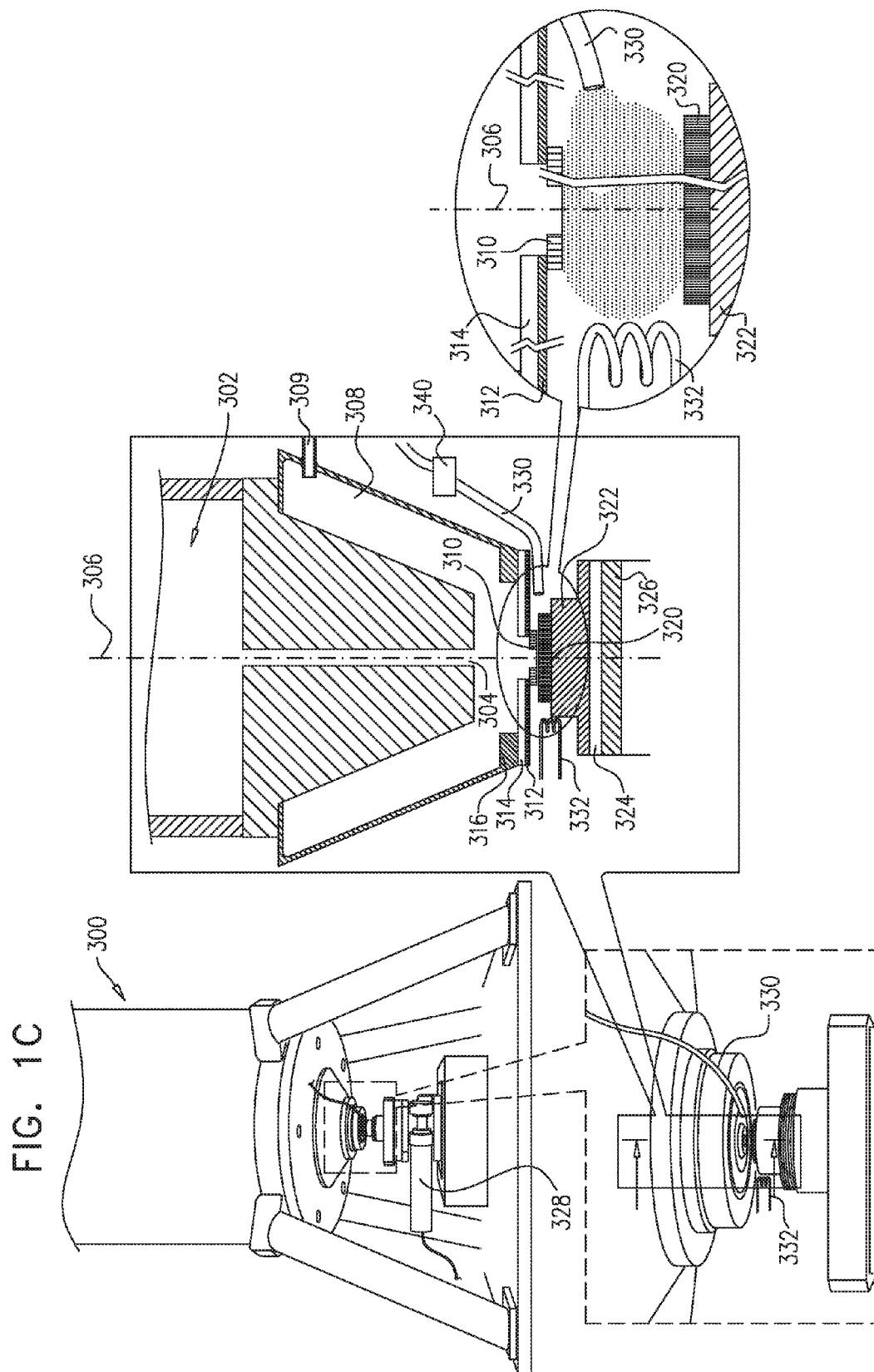
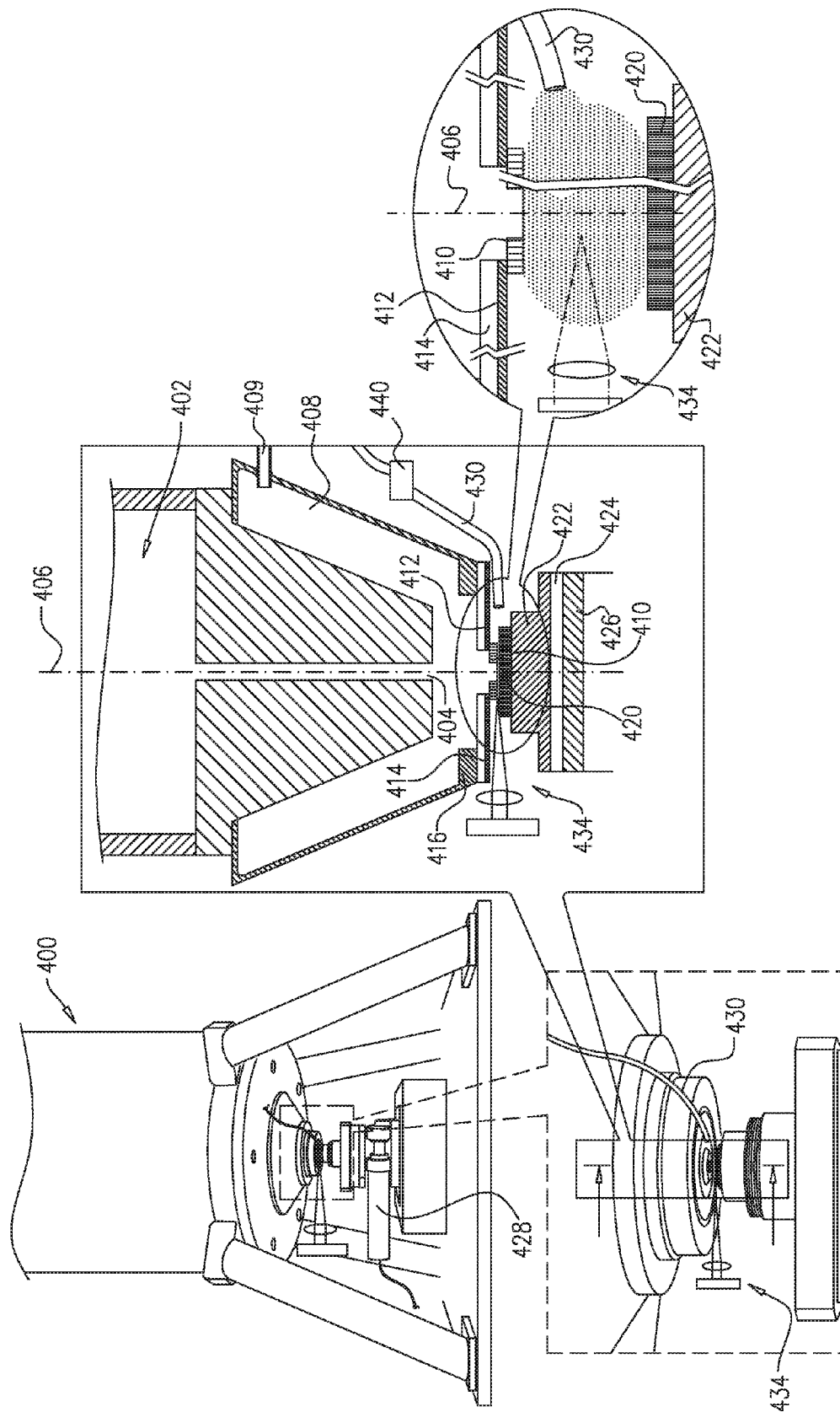
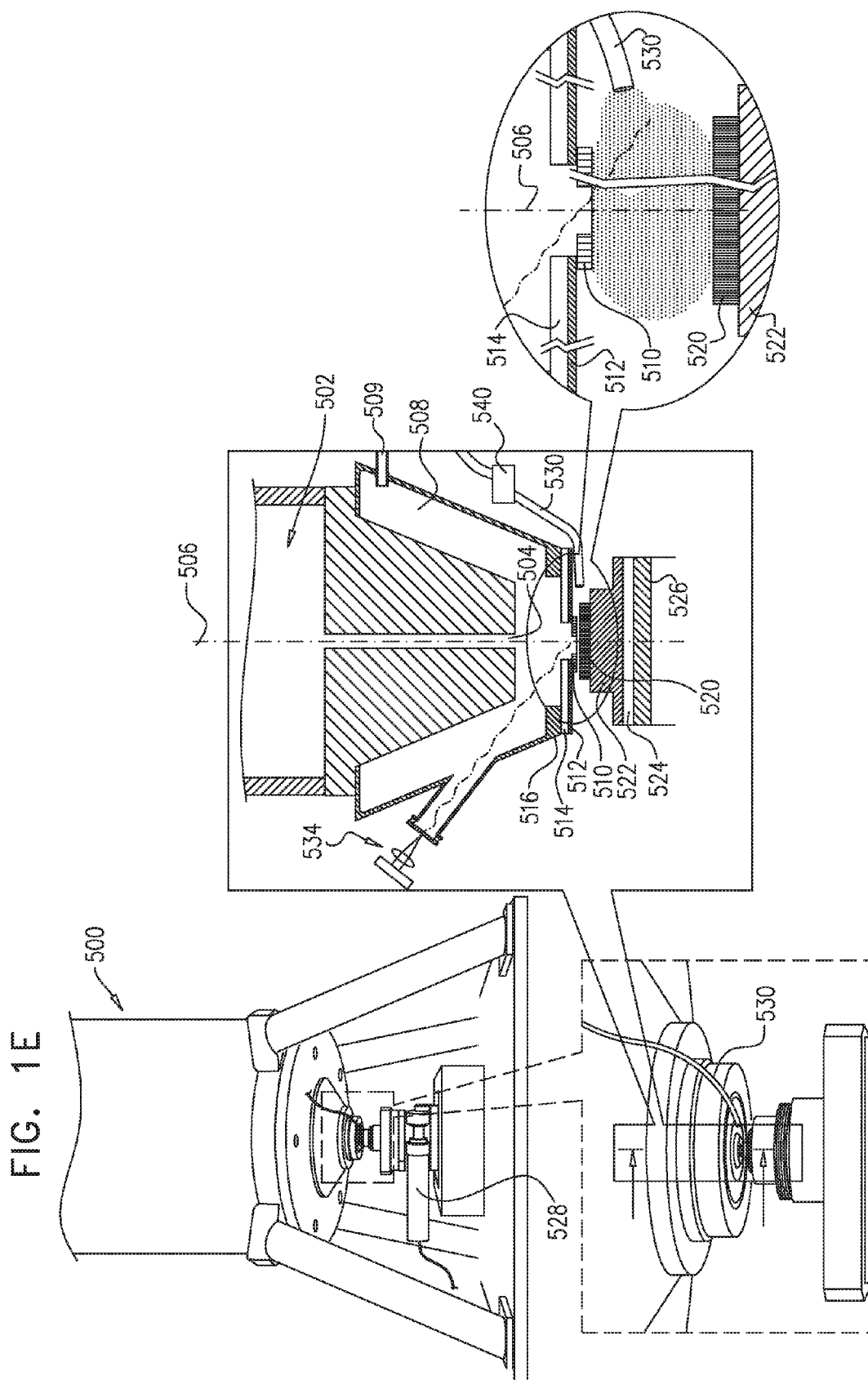
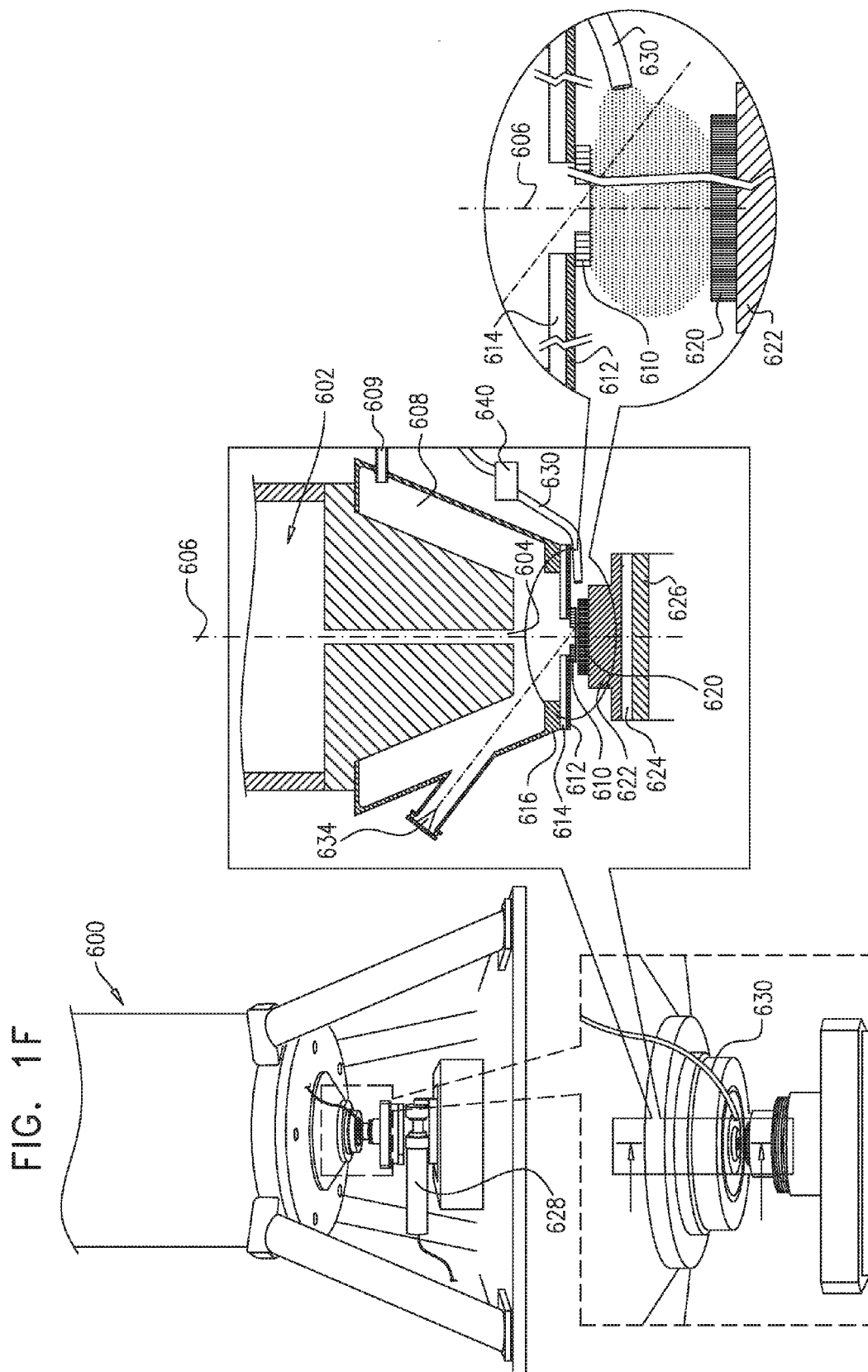
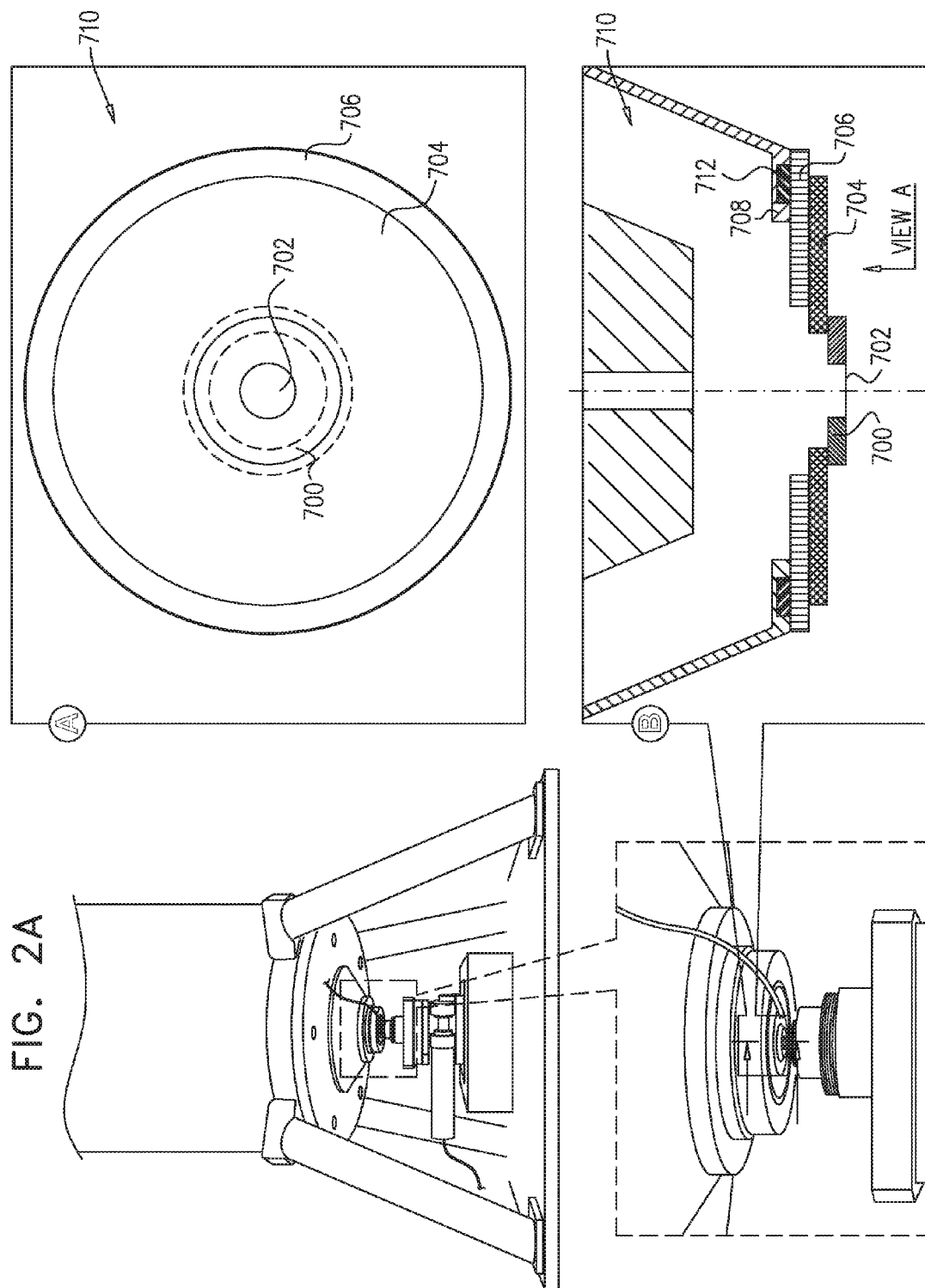


FIG. 1D









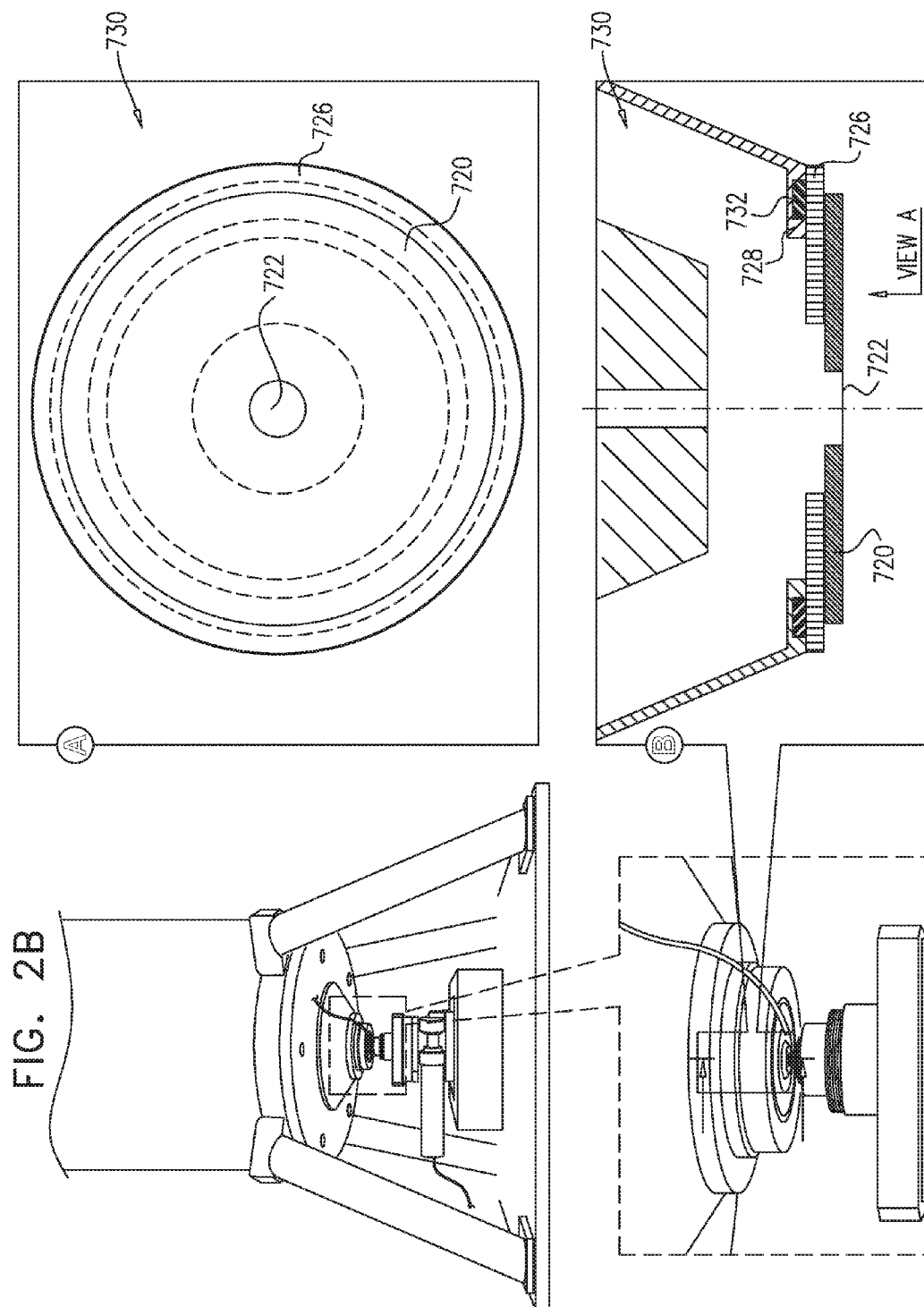
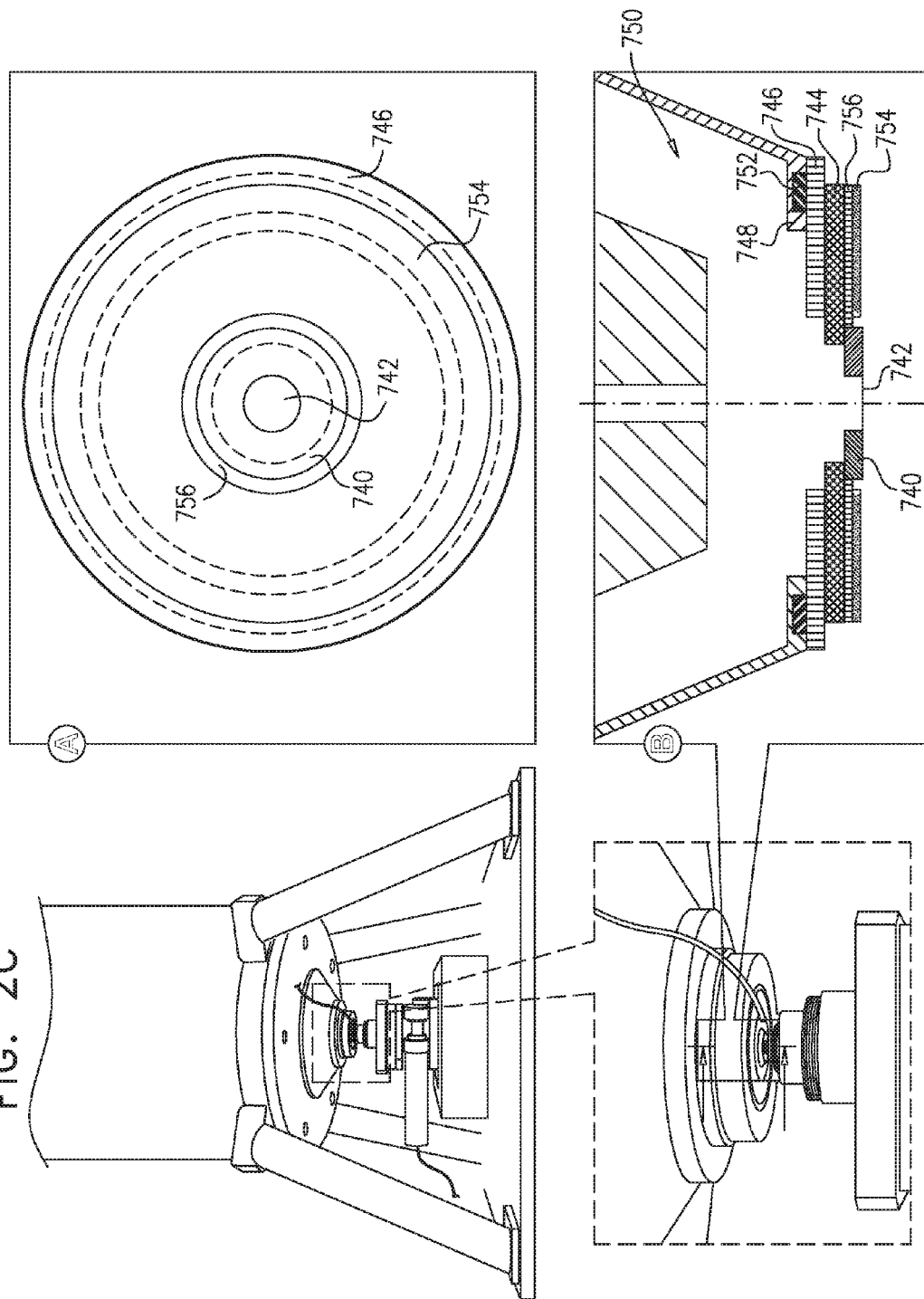
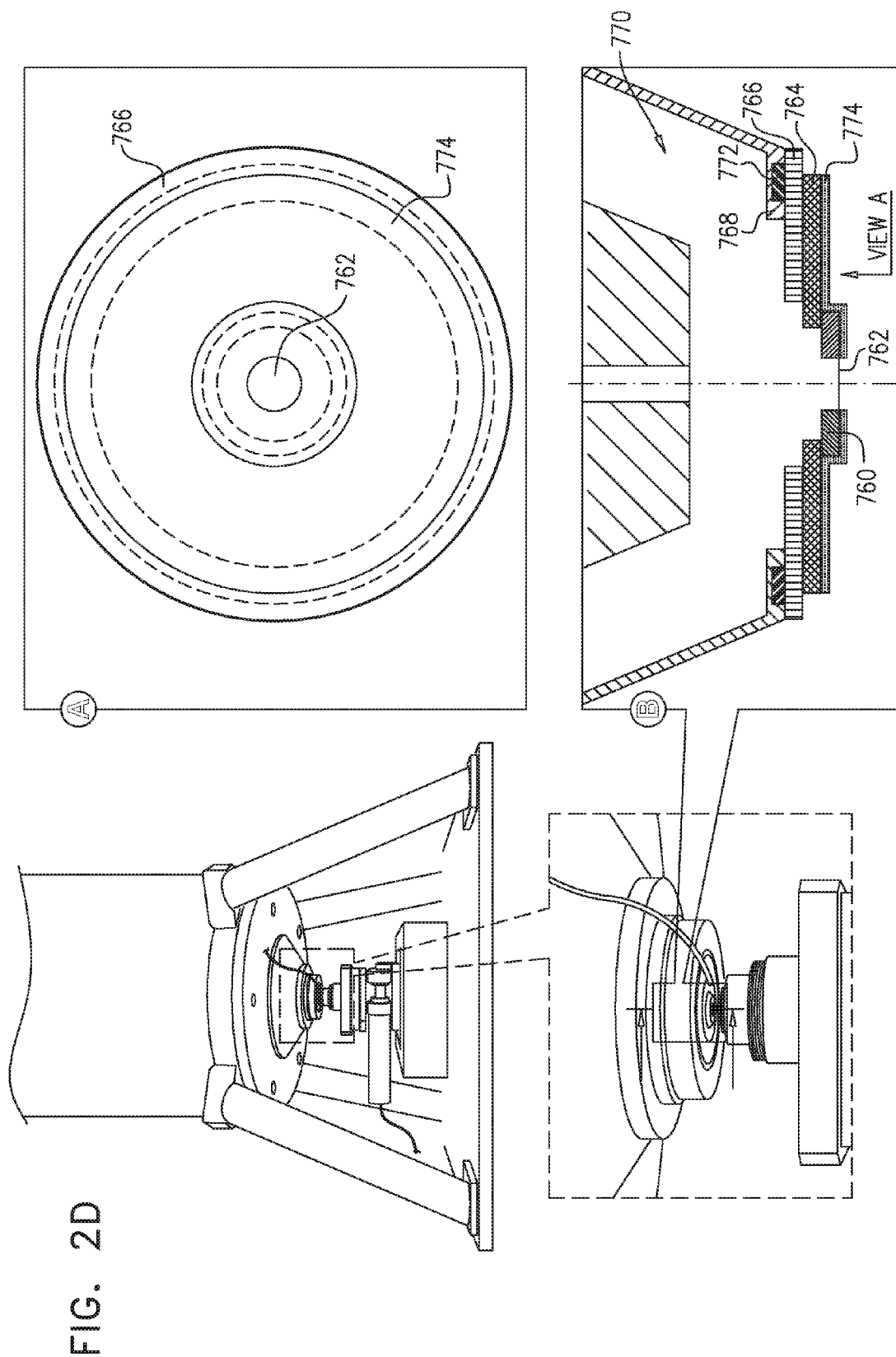
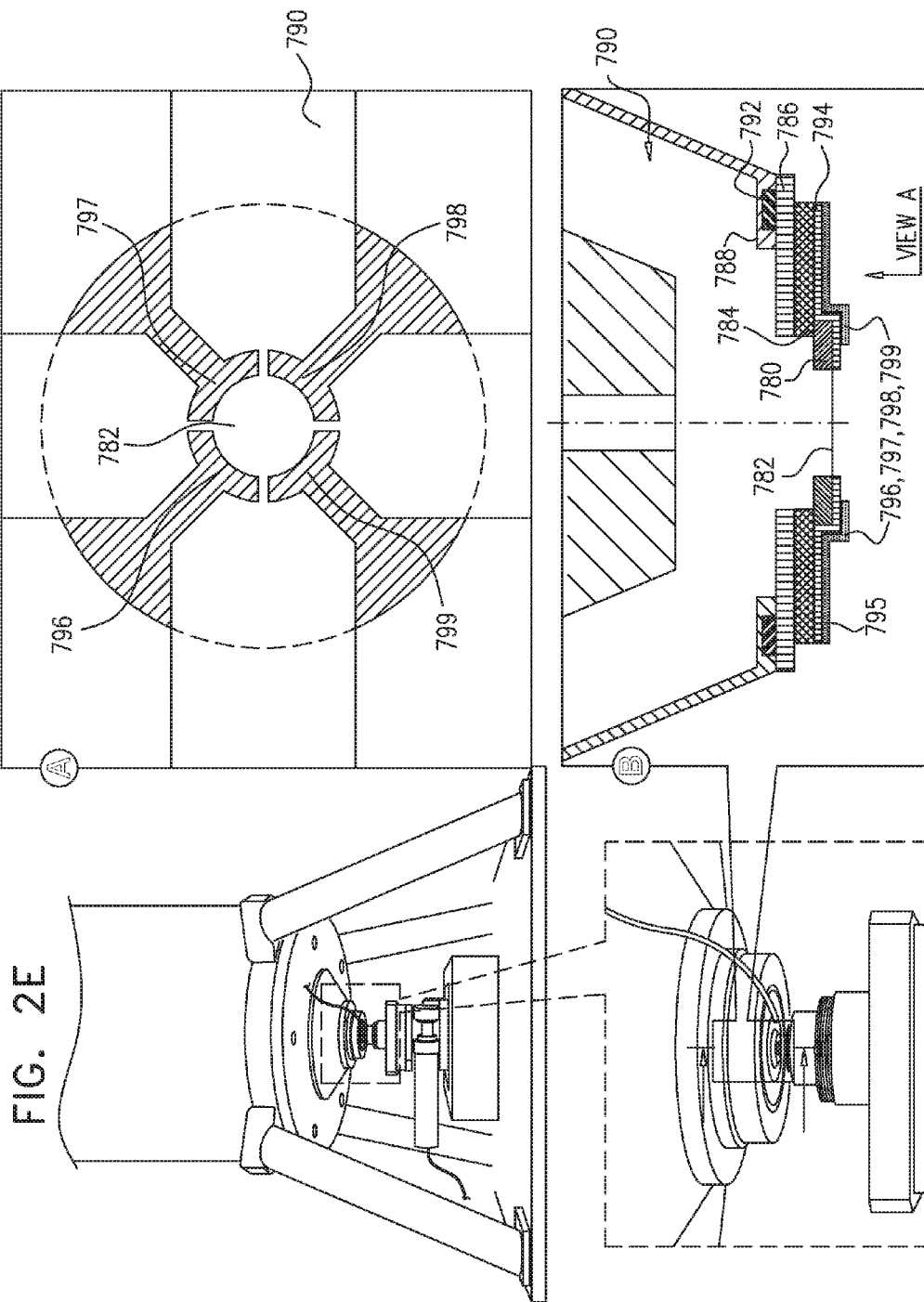


FIG. 2C







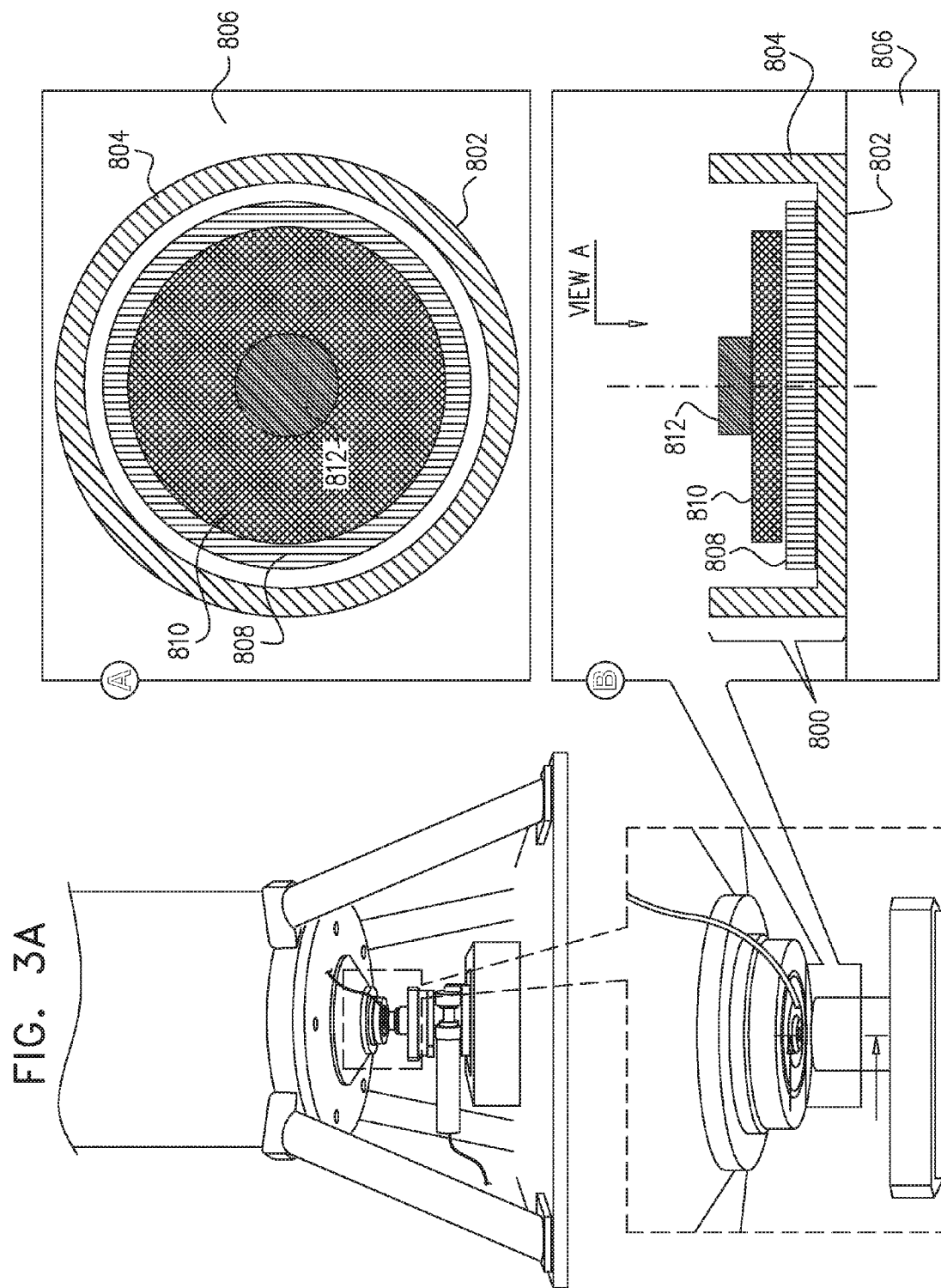
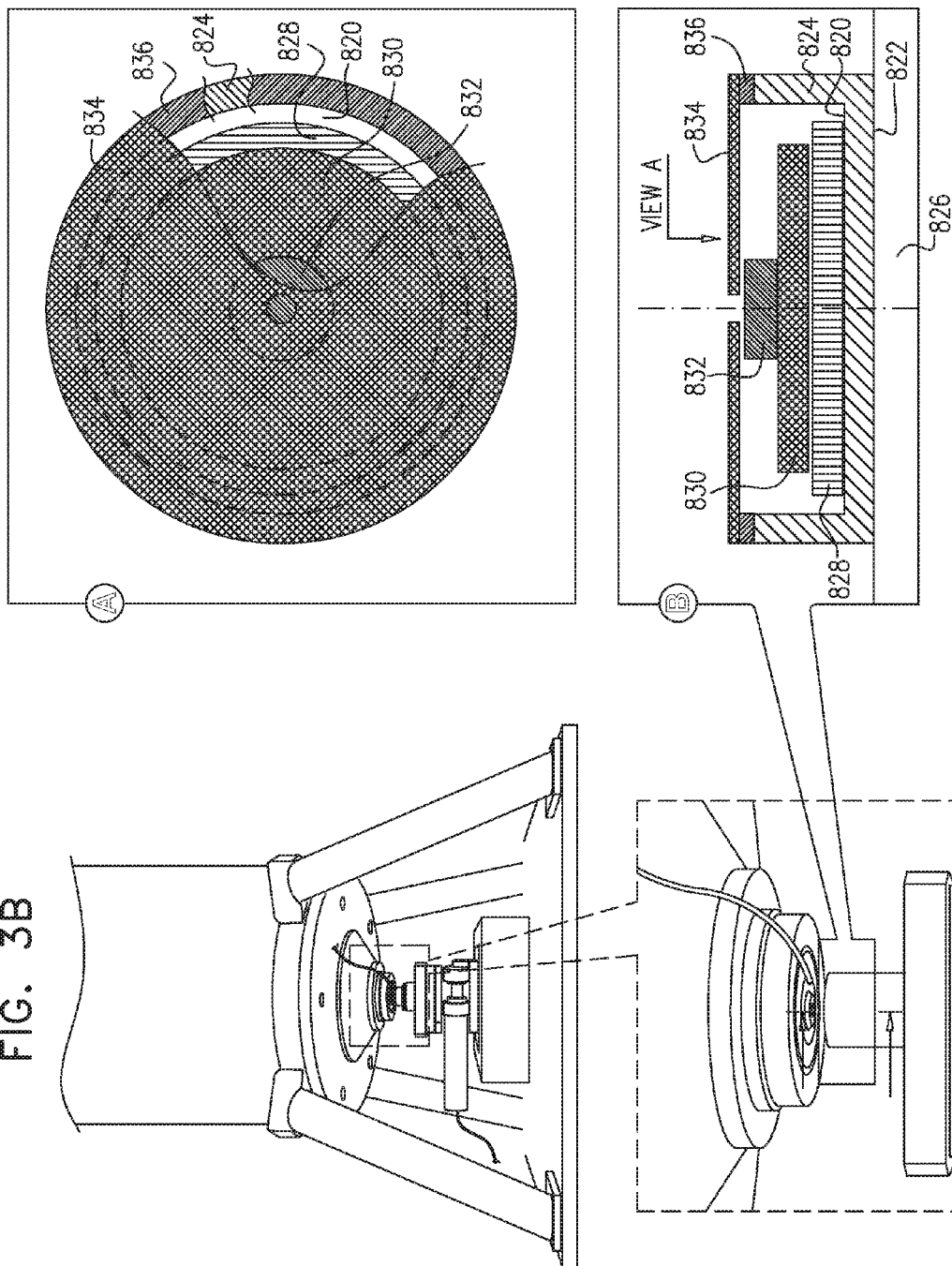
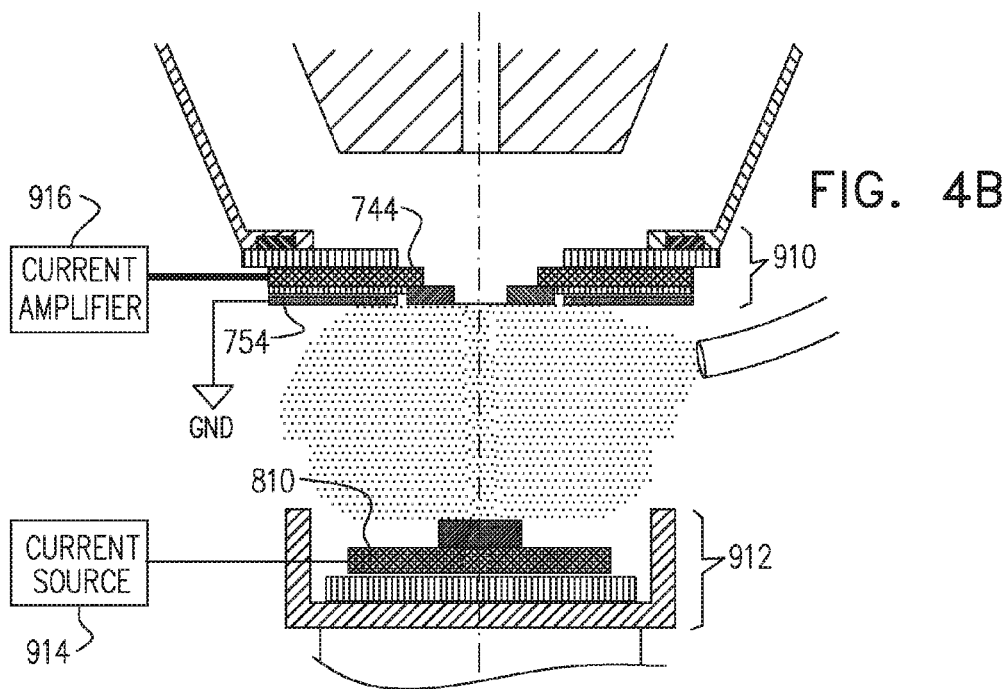
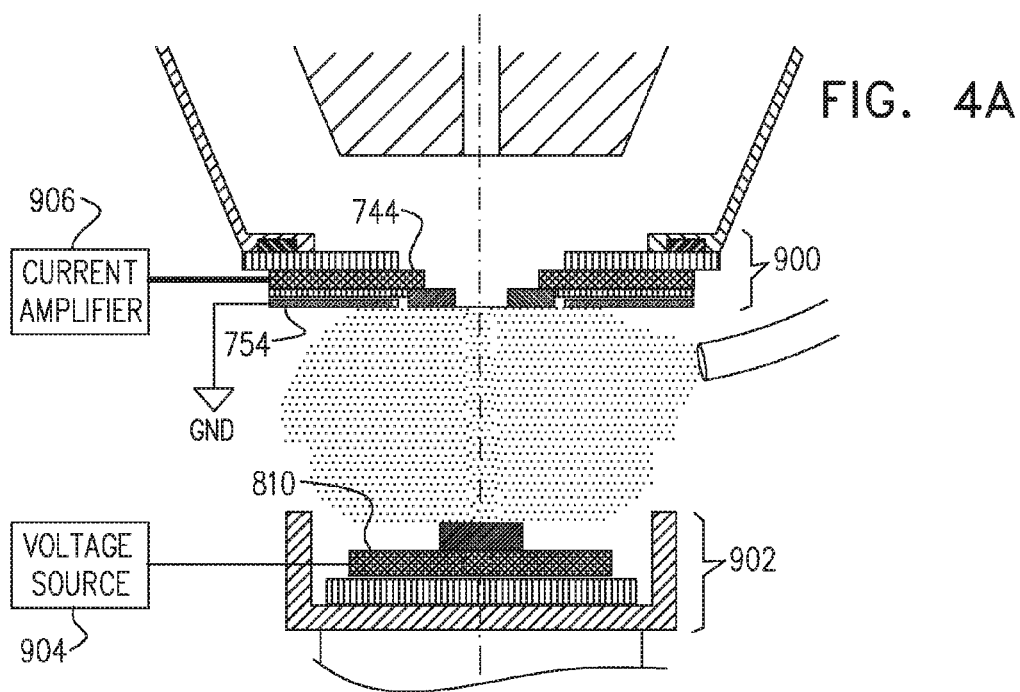
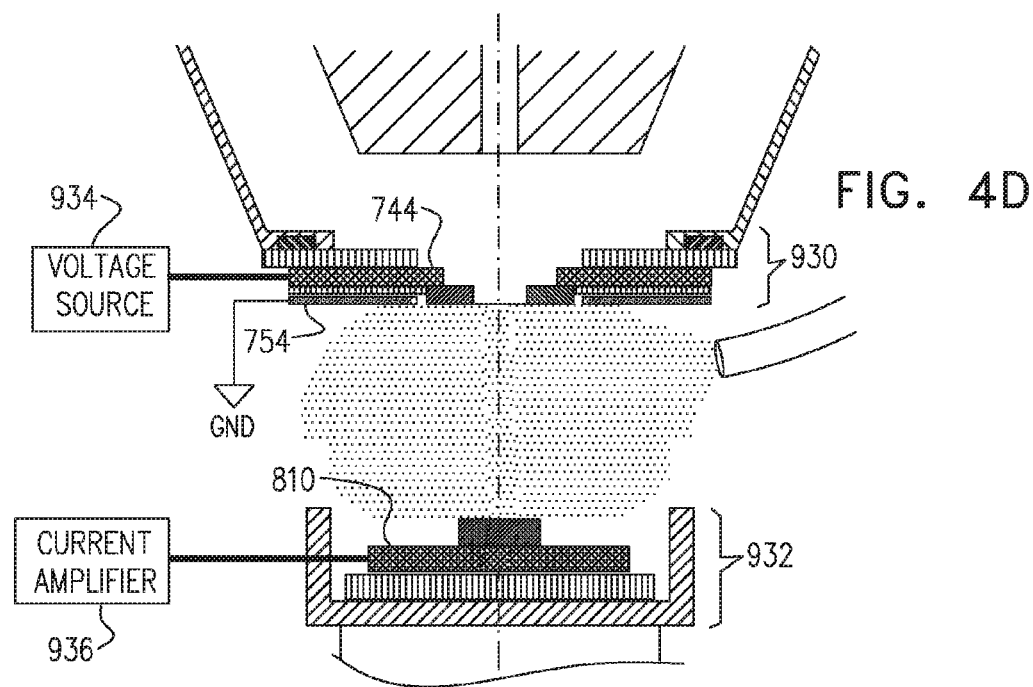
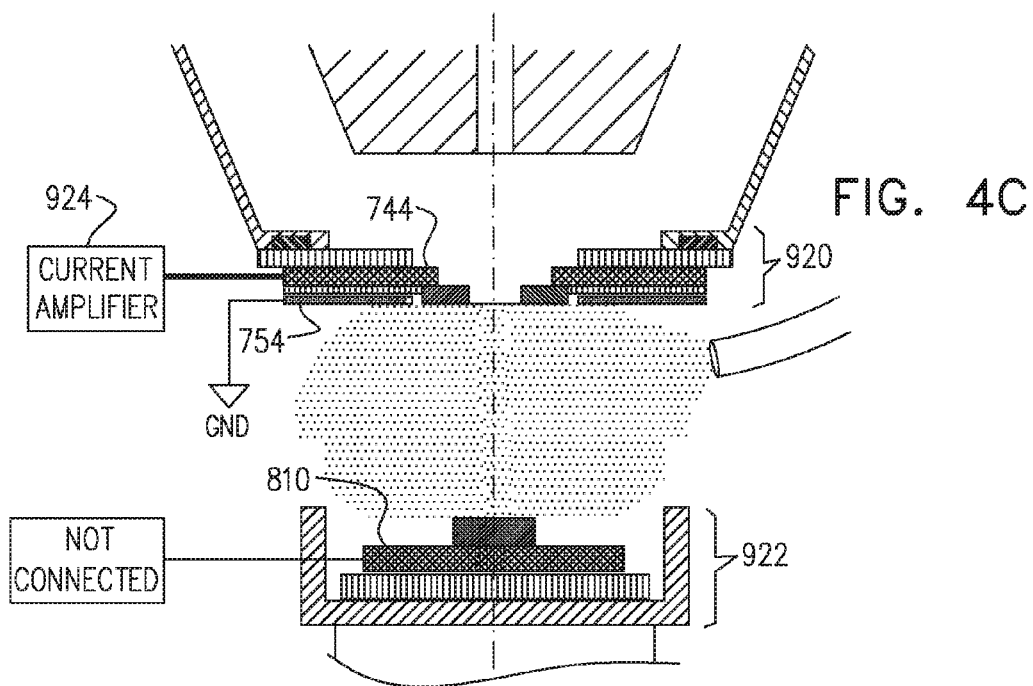
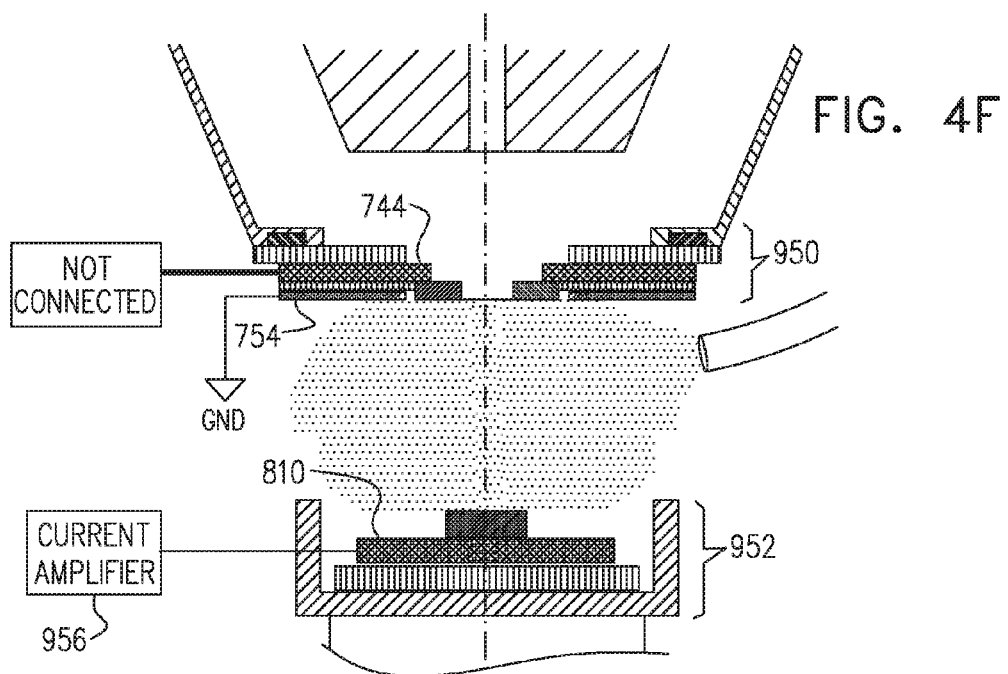
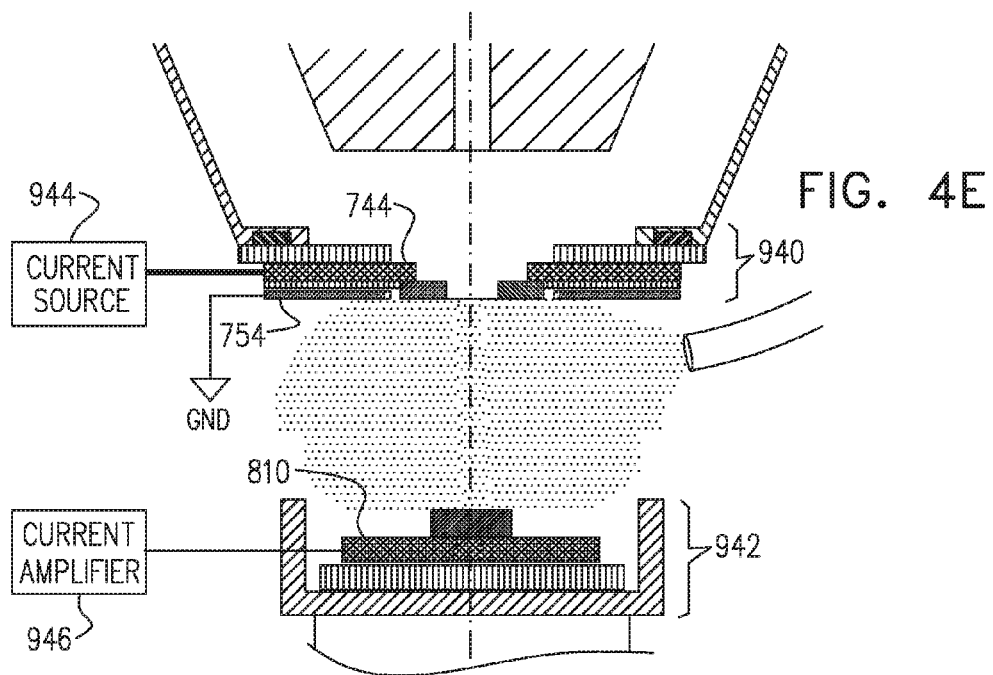


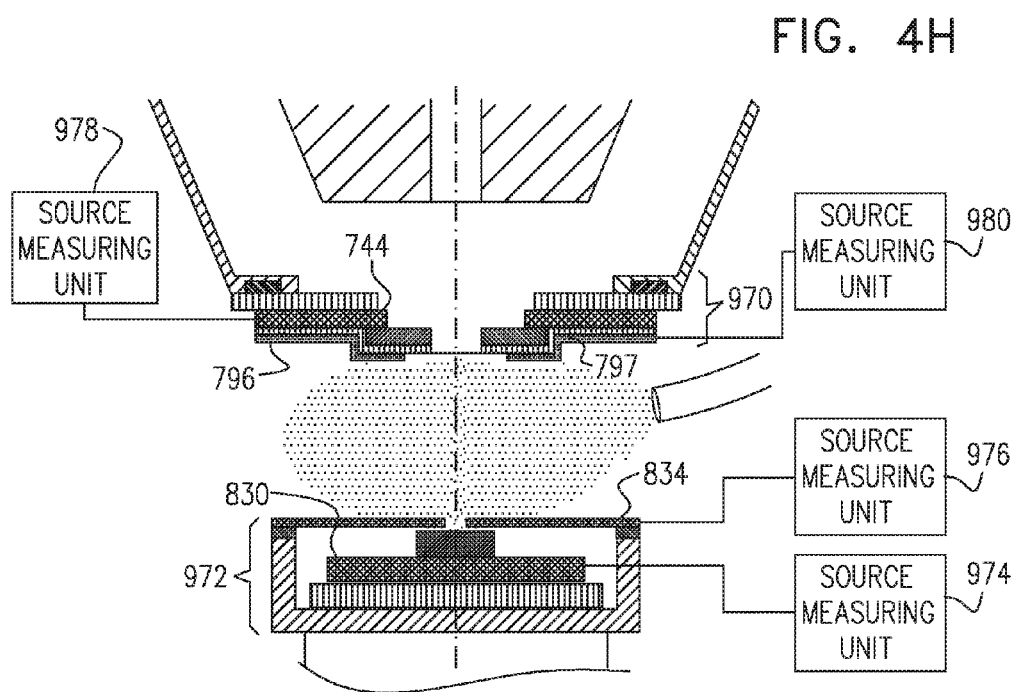
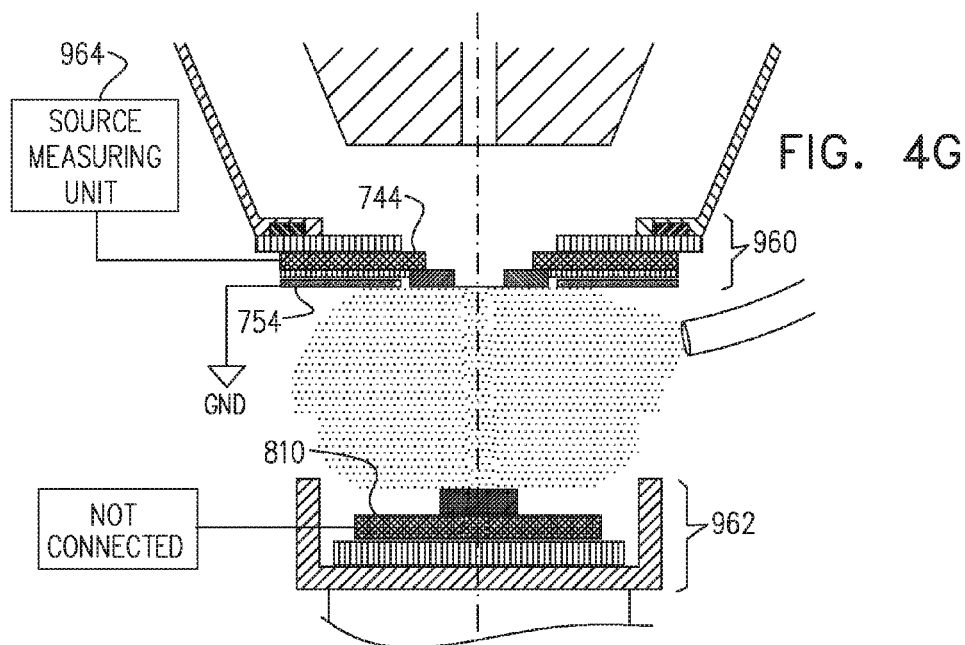
FIG. 3B











SCANNING ELECTRON MICROSCOPE**REFERENCE TO RELATED APPLICATIONS**

Reference is hereby made to U.S. Provisional Patent Application Ser. 61/766,766, filed Feb. 20, 2013 and entitled “Scanning Electron Microscope,” the disclosure of which is hereby incorporated by reference and priority of which is hereby claimed pursuant to 37 CFR 1.78(a)(4) and (5)(i).

Reference is also made to the following patent publications and pending patent applications, the contents of which are hereby incorporated by reference herein:

Published PCT Patent Application No. WO 2008/050321, entitled “An Interface, A Method For Observing An Object Within A Non-Vacuum Environment and A Scanning Electron Microscope” and filed Oct. 23, 2007;

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U.S. Provisional Patent Application Ser. No. 61/655,567, entitled “Method For Improving Lateral Resolution” and filed Jun. 5, 2012.

FIELD OF THE INVENTION

The present invention relates generally to scanning electron microscopes.

BACKGROUND OF THE INVENTION

Various different types of scanning electron microscopes are known.

SUMMARY OF THE INVENTION

The present invention seeks to provide an improved scanning electron microscope.

There is thus provided in accordance with a preferred embodiment of the present invention a scanning electron microscope suitable for imaging samples in a non-vacuum environment, the scanning electron microscope including an electron source located within an enclosure maintained under vacuum, an electron permeable membrane disposed at an opening of the enclosure separating an environment within the enclosure which is maintained under vacuum and an environment outside the enclosure which is not maintained under vacuum, the electron permeable membrane not being electrically grounded and at least one non-grounded electrode operative as an electron detector.

There is also provided in accordance with another preferred embodiment of the present invention a scanning electron microscope suitable for imaging samples in a non-vacuum environment, the scanning electron microscope including an electron source located within an enclosure maintained under vacuum, an electron permeable membrane disposed at an opening of the enclosure separating an environment within the enclosure which is maintained under vacuum and an environment outside the enclosure which is not maintained under vacuum and at least one non-grounded

electrode operative as a support for the electron permeable membrane and functioning as part of an electron detector.

There is further provided in accordance with yet another preferred embodiment of the present invention a scanning electron microscope suitable for imaging samples in a non-vacuum environment, the scanning electron microscope including an electron source located within an enclosure maintained under vacuum, an electron permeable membrane disposed at an opening of the enclosure separating an environment within the enclosure which is maintained under vacuum and an environment outside the enclosure which is not maintained under vacuum, a first non-grounded electrode operative as a support for the electron permeable membrane and functioning as part of an electron detector and a second non-grounded electrode operative associated with a sample support and functioning as part of an electron detector, a volume generally between the first and second electrodes generally being maintained at a positive pressure of less than 2 atmospheres.

There is even further provided in accordance with still another preferred embodiment of the present invention a scanning electron microscope suitable for imaging samples in a non-vacuum environment, the scanning electron microscope including an electron source located within an enclosure maintained under vacuum, an electron permeable membrane disposed at an opening of the enclosure separating an environment within the enclosure which is maintained under vacuum and an environment outside the enclosure which is not maintained under vacuum, an ionized gas generator operative to provide an ionized gas in the environment outside the enclosure and at least one non-grounded electrode operative as an electron detector.

Preferably, the scanning electron microscope suitable for imaging samples in a non-vacuum environment also includes an ionized gas generator operative to provide an ionized gas in the environment outside the enclosure.

In accordance with a preferred embodiment of the present invention the ionized gas forms a plasma.

In accordance with a preferred embodiment of the present invention the ionized gas generator includes at least one of an RF coil and an ionizing light source. Additionally or alternatively, the ionized gas generator includes a humidifier.

Preferably, the ionized gas includes humidified helium gas. Additionally, the humidified helium gas has a relative humidity of at least 30% at 20° C. More preferably, the humidified helium gas has a relative humidity of at least 50% at 20° C. Most preferably, the humidified helium gas has a relative humidity of at least 90% at 20° C.

Preferably, the at least one non-grounded electrode forms part of a support for the electron permeable membrane.

In accordance with a preferred embodiment of the present invention, the at least one non-grounded electrode is associated with a sample support.

In accordance with a preferred embodiment of the present invention the at least one non-grounded electrode is coupled to at least one of a current source and a voltage source.

Preferably, the electron detector includes at least one of a current amplifier and at least one Source Measuring Unit (SMU).

In accordance with a preferred embodiment of the present invention the scanning electron microscope suitable for imaging samples in a non-vacuum environment also includes at least one additional non-grounded electrode associated with a sample support and functioning as part of an electron detector. Additionally, at least one of the at least

one non-grounded electrode and the at least one additional non-grounded electrode is coupled to at least one of a current source and a voltage source.

Preferably, at least one of the first non-grounded electrode and the second non-grounded electrode is coupled to at least one of a current source and a voltage source.

BRIEF DESCRIPTION OF THE DRAWINGS

The present invention will be understood and appreciated more fully from the following detailed description, taken in conjunction with the drawings in which:

FIGS. 1A, 1B, 1C, 1D, 1E and 1F are simplified illustrations of various embodiments of a scanning electron microscope, constructed and operative in accordance with a preferred embodiment of the present invention;

FIGS. 2A, 2B, 2C, 2D and 2E are simplified illustrations of five alternative electrode structures useful in the scanning electron microscopes of any of FIGS. 1A-1F;

FIGS. 3A and 3B are simplified illustrations of two alternative sample holder electrode structures useful in the scanning electron microscopes of any of FIGS. 1A-2E; and

FIGS. 4A, 4B, 4C, 4D, 4E, 4F, 4G and 4H are simplified illustrations of various different electrical connections of various embodiments of scanning electron microscopes of the types shown above.

DETAILED DESCRIPTION OF A PREFERRED EMBODIMENT

Reference is now made to FIG. 1A, which illustrates a scanning electron microscope **100** constructed and operative in accordance with a preferred embodiment of the present invention. In accordance with a preferred embodiment of the present invention, the scanning electron microscope **100** includes a conventional scanning electron microscope (SEM) column **102**, an example of which is a SEM column which forms part of a Gemini® column based SEM, commercially available from Carl Zeiss SMT GmbH, Oberkochen, Germany, having a beam aperture **104** arranged along an optical axis **106** of the SEM column **102**. The SEM column **102** is typically maintained under vacuum.

A vacuum interface **108**, typically in the form of a vacuum enclosure coupled to a vacuum pump (not shown) via a conduit **109**, interfaces between the interior of the SEM column **102** at the beam aperture **104** and the ambient and is formed with a vacuum retaining, beam permeable, membrane **110**, which is aligned with the beam aperture **104** along optical axis **106**.

Membrane **110** is preferably a model 4104SN-BA membrane, commercially available from SPI Supplies, West Chester, Pa., USA. In accordance with a preferred embodiment of the invention, the membrane **110** is not electrically grounded. It is noted that the thickness of the membrane **110** is in the nanometer range and is not shown to scale.

In accordance with a preferred embodiment of the present invention, the membrane **110** is supported onto the vacuum interface **108** by means of a membrane holder **112**, typically in the form of an apertured disc formed of an electrical conductor, such as stainless steel. The membrane holder **112** sealingly underlies an electrical insulator **114**, also typically in the form of an apertured disc. The electrical insulator **114** is sealingly mounted onto an inner facing bottom flange portion **116** of vacuum interface **108**.

A sample, here designated by reference numeral **120**, is located below and spaced from membrane **110**, typically by

a distance of up to 500 microns, and is positioned such that an electron beam directed along optical axis **106** impinges thereon. Sample **120** is preferably supported by a sample holder **122**. Sample holder **122** is preferably formed of an electrical conductor, such as stainless steel or aluminum, and is not grounded. Sample holder **122** preferably is supported via an electrical insulator **124** onto a sample mount **126**, which may form part of a sample manipulator **128**.

Preferably, a gas, such as helium or nitrogen, is injected into the space between membrane **110** and sample **120**, typically by means of one or more supply conduits **130**.

It is a particular feature of an embodiment of the present invention that humidified helium gas is injected via one or more supply conduits **130**. Preferably, the humidified helium gas is provided by passing at least 99% pure helium gas through a humidifier **140**, such as a PDMSXA-2500 from MedArray, Inc., Ann Arbor, Mich., USA. Preferably, the relative humidity of the humidified helium gas is at least 30% at 20° C., more preferably, the relative humidity of the humidified helium gas is at least 50% at 20° C. and most preferably, the relative humidity of the humidified helium gas is at least 90% at 20° C.

In accordance with a preferred embodiment of the present invention, a volume formed between membrane holder **112**, which is operative as a first electrode, and sample holder **122**, which is operative as a second electrode, is maintained at a positive pressure of less than 2 atmospheres.

Reference is now made to FIG. 1B, which illustrates a scanning electron microscope **200** constructed and operative in accordance with another preferred embodiment of the present invention. In accordance with a preferred embodiment of the present invention, the scanning electron microscope **200** includes a conventional SEM column **202**, an example of which is a SEM column which forms part of a Gemini® column based SEM, commercially available from Carl Zeiss SMT GmbH, Oberkochen, Germany, having a beam aperture **204** arranged along an optical axis **206** of the SEM column **202**. The SEM column **202** is typically maintained under vacuum.

A vacuum interface **208**, typically in the form of a vacuum enclosure coupled to a vacuum pump (not shown) via a conduit **209**, interfaces between the interior of the SEM column **202** at the beam aperture **204** and the ambient and is formed with a vacuum retaining, beam permeable, membrane **210**, which is aligned with the beam aperture **204** along optical axis **206**.

Membrane **210** is preferably a model 4104SN-BA membrane, commercially available from SPI Supplies, West Chester, Pa., USA. In accordance with a preferred embodiment of the invention, the membrane **210** is not electrically grounded. It is noted that the thickness of the membrane **210** is in the nanometer range and is not shown to scale.

In accordance with a preferred embodiment of the present invention, the membrane **210** is supported onto the vacuum interface **208** by means of a membrane holder **212**, typically in the form of an apertured disc formed of an electrical conductor, such as stainless steel. The membrane holder **212** sealingly underlies an electrical insulator **214**, also typically in the form of an apertured disc. The electrical insulator **214** is sealingly mounted onto an inner facing bottom flange portion **216** of vacuum interface **208**.

A sample, here designated by reference numeral **220**, is located below and spaced from membrane **210**, typically by a distance of up to 500 microns, and is positioned such that an electron beam directed along optical axis **206** impinges thereon. Sample **220** is preferably supported by a sample holder **222**. Sample holder **222** is preferably formed of an

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electrical conductor, such as stainless steel or aluminum, and may or may not be grounded, depending on the application. Sample holder 222 may be supported via an electrical insulator 224 onto a sample mount 226, which may form part of a sample manipulator 228.

Preferably, a gas, such as helium or nitrogen, is injected into the space between membrane 210 and sample 220, typically by means of one or more supply conduits 230. In accordance with a preferred embodiment of the present invention, an RF coil 232 is provided preferably surrounding conduit 230 to ionize the gas passing therethrough and thus produce a plasma in the space between membrane 210 and sample 220.

It is a particular feature of an embodiment of the present invention that humidified helium gas is injected via one or more supply conduits 230. Preferably, the humidified helium gas is provided by passing at least 99% pure helium gas through a humidifier 240, such as a PDMSXA-2500 from MedArray, Inc., Ann Arbor, Mich., USA. Preferably, the relative humidity of the humidified helium gas is at least 30% at 20° C., more preferably, the relative humidity of the humidified helium gas is at least 50% at 20° C. and most preferably, the relative humidity of the humidified helium gas is at least 90% at 20° C.

In accordance with a preferred embodiment of the present invention, a volume formed between membrane holder 212, which is operative as a first electrode, and sample holder 222, which is operative as a second electrode, is maintained at a positive pressure of less than 2 atmospheres.

Reference is now made to FIG. 1C, which illustrates a scanning electron microscope 300 constructed and operative in accordance with another preferred embodiment of the present invention. In accordance with a preferred embodiment of the present invention, the scanning electron microscope 300 includes a conventional SEM column 302, an example of which is a SEM column which forms part of a Gemini® column based SEM, commercially available from Carl Zeiss SMT GmbH, Oberkochen, Germany, having a beam aperture 304 arranged along an optical axis 306 of the SEM column 302. The SEM column 302 is typically maintained under vacuum.

A vacuum interface 308, typically in the form of a vacuum enclosure coupled to a vacuum pump (not shown) via a conduit 309, interfaces between the interior of the SEM column 302 at the beam aperture 304 and the ambient and is formed with a vacuum retaining, beam permeable, membrane 310, which is aligned with the beam aperture 304 along optical axis 306.

Membrane 310 is preferably a model 4104SN-BA membrane, commercially available from SPI Supplies, West Chester, Pa., USA. In accordance with a preferred embodiment of the invention, the membrane 310 is not electrically grounded. It is noted that the thickness of the membrane 310 is in the nanometer range and is not shown to scale.

In accordance with a preferred embodiment of the present invention, the membrane 310 is supported onto the vacuum interface 308 by means of a membrane holder 312, typically in the form of an apertured disc formed of an electrical conductor, such as stainless steel. The membrane holder 312 sealingly underlies an electrical insulator 314, also typically in the form of an apertured disc. The electrical insulator 314 is sealingly mounted onto an inner facing bottom flange portion 316 of vacuum interface 308.

A sample, here designated by reference numeral 320, is located below and spaced from membrane 310, typically by a distance of up to 500 microns and is positioned such that an electron beam directed along optical axis 306 impinges

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thereon. Sample 320 is preferably supported by a sample holder 322. Sample holder 322 is preferably formed of an electrical conductor, such as stainless steel or aluminum, and may or may not be grounded, depending on the application.

Sample holder 322 may be supported via an electrical insulator 324 onto a sample mount 326, which may form part of a sample manipulator 328.

Preferably, a gas, such as helium or nitrogen, is injected into the space between membrane 310 and sample 320 typically by means of one or more supply conduits 330. In accordance with a preferred embodiment of the present invention, an RF coil 332 is provided alongside the space between membrane 310 and sample 320 to ionize the gas located therein and thus produce a plasma in the space between membrane 310 and sample 320.

It is a particular feature of an embodiment of the present invention that humidified helium gas is injected via one or more supply conduits 330. Preferably, the humidified helium gas is provided by passing at least 99% pure helium gas through a humidifier 340, such as a PDMSXA-2500 from MedArray, Inc., Ann Arbor, Mich., USA. Preferably, the relative humidity of the humidified helium gas is at least 30% at 20° C., more preferably, the relative humidity of the humidified helium gas is at least 50% at 20° C. and most preferably, the relative humidity of the humidified helium gas is at least 90% at 20° C.

In accordance with a preferred embodiment of the present invention, a volume formed between membrane holder 312, which is operative as a first electrode, and sample holder 322, which is operative as a second electrode, is maintained at a positive pressure of less than 2 atmospheres.

Reference is now made to FIG. 1D, which illustrates a scanning electron microscope 400 constructed and operative in accordance with another preferred embodiment of the present invention. In accordance with a preferred embodiment of the present invention, the scanning electron microscope 400 includes a conventional SEM column 402, an example of which is a SEM column which forms part of a Gemini® column based SEM, commercially available from Carl Zeiss SMT GmbH, Oberkochen, Germany, having a beam aperture 404 arranged along an optical axis 406 of the SEM column 402. The SEM column 402 is typically maintained under vacuum.

A vacuum interface 408, typically in the form of a vacuum enclosure coupled to a vacuum pump (not shown) via a conduit 409, interfaces between the interior of the SEM column 402 at the beam aperture 404 and the ambient and is formed with a vacuum retaining, beam permeable, membrane 410, which is aligned with the beam aperture 404 along optical axis 406.

Membrane 410 is preferably a model 4104SN-BA membrane, commercially available from SPI Supplies, West Chester, Pa., USA. In accordance with a preferred embodiment of the invention, the membrane 410 is not electrically grounded. It is noted that the thickness of the membrane 410 is in the nanometer range and is not shown to scale.

In accordance with a preferred embodiment of the present invention, the membrane 410 is supported onto the vacuum interface 408 by means of a membrane holder 412, typically in the form of an apertured disc formed of an electrical conductor, such as stainless steel. The membrane holder 412 sealingly underlies an electrical insulator 414, also typically in the form of an apertured disc. The electrical insulator 414 is sealingly mounted onto an inner facing bottom flange portion 416 of vacuum interface 408.

A sample, here designated by reference numeral 420, is located below and spaced from membrane 410, typically by

a distance of up to 500 microns, and is positioned such that an electron beam directed along optical axis **406** impinges thereon. Sample **420** is preferably supported by a sample holder **422**. Sample holder **422** is preferably formed of an electrical conductor, such as stainless steel or aluminum, and may or may not be grounded, depending on the application. Sample holder **422** may be supported via an electrical insulator **424** onto a sample mount **426**, which may form part of a sample manipulator **428**.

Preferably, a gas, such as helium or nitrogen, is injected into the space between membrane **410** and sample **420**, typically by means of one or more supply conduits **430**. In accordance with a preferred embodiment of the present invention, an ionizing light source **434**, such as a laser or a mercury lamp, is provided alongside the space between membrane **410** and sample **420** to ionize the gas located therein and thus produce a plasma in the space between membrane **410** and sample **420**.

It is a particular feature of an embodiment of the present invention that humidified helium gas is injected via one or more supply conduits **430**. Preferably, the humidified helium gas is provided by passing at least 99% pure helium gas through a humidifier **440**, such as a PDMSXA-2500 from MedArray, Inc., Ann Arbor, Mich., USA. Preferably, the relative humidity of the humidified helium gas is at least 30% at 20° C., more preferably, the relative humidity of the humidified helium gas is at least 50% at 20° C. and most preferably, the relative humidity of the humidified helium gas is at least 90% at 20° C.

In accordance with a preferred embodiment of the present invention, a volume formed between membrane holder **412**, which is operative as a first electrode, and sample holder **422**, which is operative as a second electrode, is maintained at a positive pressure of less than 2 atmospheres.

Reference is now made to FIG. 1E, which illustrates a scanning electron microscope **500** constructed and operative in accordance with another preferred embodiment of the present invention. In accordance with a preferred embodiment of the present invention, the scanning electron microscope **500** includes a conventional SEM column **502**, an example of which is a SEM column which forms part of a Gemini® column based SEM, commercially available from Carl Zeiss SMT GmbH, Oberkochen, Germany, having a beam aperture **504** arranged along an optical axis **506** of the SEM column **502**. The SEM column **502** is typically maintained under vacuum.

A vacuum interface **508**, typically in the form of a vacuum enclosure coupled to a vacuum pump (not shown) via a conduit **509**, interfaces between the interior of the SEM column **502** at the beam aperture **504** and the ambient and is formed with a vacuum retaining, beam permeable membrane **510**, which is aligned with the beam aperture **504** along optical axis **506**.

Membrane **510** is preferably a model 4104SN-BA membrane, commercially available from SPI Supplies, West Chester, Pa., USA. In accordance with a preferred embodiment of the invention, the membrane **510** is not electrically grounded. It is noted that the thickness of the membrane **510** is in the nanometer range and is not shown to scale.

In accordance with a preferred embodiment of the present invention, the membrane **510** is supported onto the vacuum interface **508** by means of a membrane holder **512**, typically in the form of an apertured disc formed of an electrical conductor, such as stainless steel. The membrane holder **512** sealingly underlies an electrical insulator **514**, also typically in the form of an apertured disc. The electrical insulator **514**

is sealingly mounted onto an inner facing bottom flange portion **516** of vacuum interface **508**.

A sample, here designated by reference numeral **520**, is located below and spaced from membrane **510**, typically by a distance of up to 500 microns and is positioned such that an electron beam directed along optical axis **506** impinges thereon. Sample **520** is preferably supported by a sample holder **522**. Sample holder **522** is preferably formed of an electrical conductor, such as stainless steel or aluminum, and may or may not be grounded, depending on the application. Sample holder **522** may be supported via an electrical insulator **524** onto a sample mount **526**, which may form part of a sample manipulator **528**.

Preferably, a gas, such as helium or nitrogen, is injected into the space between membrane **510** and sample **520**, typically by means of one or more supply conduits **530**. In accordance with a preferred embodiment of the present invention, an ionizing light source **534**, such as a laser or a mercury lamp, directs an ionizing light beam through vacuum interface **508** and membrane **510** to ionize the gas located in the space between membrane **510** and sample **520** and thus to produce a plasma in the space between membrane **510** and sample **520**.

It is a particular feature of an embodiment of the present invention that humidified helium gas is injected via one or more supply conduits **530**. Preferably, the humidified helium gas is provided by passing at least 99% pure helium gas through a humidifier **540**, such as a PDMSXA-2500 from MedArray, Inc., Ann Arbor, Mich., USA. Preferably, the relative humidity of the humidified helium gas is at least 30% at 20° C., more preferably, the relative humidity of the humidified helium gas is at least 50% at 20° C. and most preferably, the relative humidity of the humidified helium gas is at least 90% at 20° C.

In accordance with a preferred embodiment of the present invention, a volume formed between membrane holder **512**, which is operative as a first electrode, and sample holder **522**, which is operative as a second electrode, is maintained at a positive pressure of less than 2 atmospheres.

Reference is now made to FIG. 1F, which illustrates a scanning electron microscope **600** constructed and operative in accordance with another preferred embodiment of the present invention. In accordance with a preferred embodiment of the present invention, the scanning electron microscope **600** includes a conventional SEM column **602**, an example of which is a SEM column which forms part of a Gemini® column based SEM, commercially available from Carl Zeiss SMT GmbH, Oberkochen, Germany, having a beam aperture **604** arranged along an optical axis **606** of the SEM column **602**. The SEM column **602** is typically maintained under vacuum.

A vacuum interface **608**, typically in the form of a vacuum enclosure coupled to a vacuum pump (not shown) via a conduit **609**, interfaces between the interior of the SEM column **602** at the beam aperture **604** and the ambient and is formed with a vacuum retaining, beam permeable membrane **610**, which is aligned with the beam aperture **604** along optical axis **606**.

Membrane **610** is preferably a model 4104SN-BA membrane, commercially available from SPI Supplies, West Chester, Pa., USA. In accordance with a preferred embodiment of the invention, the membrane **610** is not electrically grounded. It is noted that the thickness of the membrane **610** is in the nanometer range and is not shown to scale.

In accordance with a preferred embodiment of the present invention, the membrane **610** is supported onto the vacuum interface **608** by means of a membrane holder **612**, typically

in the form of an apertured disc formed of an electrical conductor, such as stainless steel. The membrane holder **612** sealingly underlies an electrical insulator **614**, also typically in the form of an apertured disc. The electrical insulator **614** is sealingly mounted onto an inner facing bottom flange portion **616** of vacuum interface **608**.

A sample, here designated by reference numeral **620**, is located below and spaced from membrane **610**, typically by a distance of up to 500 microns, and is positioned such that an electron beam directed along optical axis **606** impinges thereon. Sample **620** is preferably supported by a sample holder **622**. Sample holder **622** is preferably formed of an electrical conductor, such as stainless steel or aluminum, and may or may not be grounded, depending on the application. Sample holder **622** may be supported via an electrical insulator **624** onto a sample mount **626**, which may form part of a sample manipulator **628**.

Preferably, a gas, such as helium or nitrogen, is injected into the space between membrane **610** and sample **620** typically by means of one or more supply conduits **630**. In accordance with a preferred embodiment of the present invention, an electron beam source **634** directs an electron beam, preferably having an energy of 1-10 KeV, through vacuum interface **608** and membrane **610** to ionize the gas located in the space between membrane **610** and sample **620** and thus to produce a plasma in the space between membrane **610** and sample **620**.

It is a particular feature of an embodiment of the present invention that humidified helium gas is injected via one or more supply conduits **630**. Preferably, the humidified helium gas is provided by passing at least 99% pure helium gas through a humidifier **640**, such as a PDMSXA-2500 from MedArray, Inc., Ann Arbor, Mich., USA. Preferably, the relative humidity of the humidified helium gas is at least 30% at 20° C., more preferably, the relative humidity of the humidified helium gas is at least 50% at 20° C. and most preferably, the relative humidity of the humidified helium gas is at least 90% at 20° C.

In accordance with a preferred embodiment of the present invention, a volume formed between membrane holder **612**, which is operative as a first electrode, and sample holder **622**, which is operative as a second electrode, is maintained at a positive pressure of less than 2 atmospheres.

Reference is now made to FIGS. 2A-2E, which are simplified illustrations of five alternative electrode structures useful in the scanning electron microscopes of any of FIGS. 1A-1F.

Turning to FIG. 2A, it is seen that the vacuum retaining, beam permeable membrane comprises an electrically conductive peripheral membrane support frame **700**, typically formed of silicon or stainless steel, onto which is attached a relatively thin membrane portion **702**, preferably formed of silicon nitride, silicon, carbon, or a polymer, preferably of thickness less than 100 nm and more preferably between 2-50 nm. One example of such a membrane support frame **700** and a thin membrane portion **702** is a model 4104SN-BA 30 nm silicon nitride membrane, commercially available from SPI Supplies, West Chester, Pa., USA.

Membrane support frame **700** is sealingly adhered to an electrically conductive membrane support **704**, which in turn sealingly mounted under an electrically insulative disc **706**. Insulative disc **706** is sealingly adhered to the underside of a flange portion **708** of a vacuum interface **710**, which is preferably formed with a sealing ring **712** to enhance sealing between flange portion **708** and insulative disc **706**.

Turning now to FIG. 2B, it is seen that here a vacuum retaining, beam permeable membrane comprises an electri-

cally conductive peripheral membrane support frame **720**, typically formed of silicon or stainless steel, onto which is attached a relatively thin membrane portion **722**, preferably formed of silicon nitride, silicon, carbon, or a polymer, preferably of thickness less than 100 nm and more preferably between 2-50 nm. One example of such a membrane support frame **720** and a thin membrane portion **722** is a model 4104SN-BA 30 nm silicon nitride membrane, commercially available from SPI Supplies, West Chester, Pa., USA.

Membrane support frame **720** is sealingly mounted under an electrically insulative disc **726**. Insulative disc **726** is sealingly adhered to the underside of a flange portion **728** of a vacuum interface **730**, which is preferably formed with a sealing ring **732** to enhance sealing between flange portion **728** and insulative disc **726**.

Turning now to FIG. 2C, it is seen that here, a vacuum retaining, beam permeable membrane comprises a peripheral membrane support frame **740**, typically formed of silicon or stainless steel, onto which is attached a relatively thin membrane portion **742**, preferably formed of silicon nitride, silicon, carbon, or a polymer, preferably of thickness less than 100 nm and more preferably between 2-50 nm. One example of such a membrane support frame **740** and a thin membrane portion **742** is a model 4104SN-BA 30 nm silicon nitride membrane, commercially available from SPI Supplies, West Chester, Pa., USA.

Membrane support frame **740** is sealingly adhered to an electrically conductive membrane support **744**, which in turn sealingly mounted under an electrically insulative disc **746**. Insulative disc **746** is sealingly adhered to the underside of a flange portion **748** of a vacuum interface **750**, which is preferably formed with a sealing ring **752** to enhance sealing between flange portion **748** and insulative disc **746**.

As distinguished from the embodiment of FIG. 2A, there is additionally provided a conductive disc **754** adhered to and underlying an insulative disc **756**, which in turn is adhered to and underlies conductive membrane support **744**.

Turning now to FIG. 2D, it is seen that here, a vacuum retaining, beam permeable membrane comprises a peripheral membrane support frame **760**, typically formed of silicon or stainless steel, onto which is attached a relatively thin membrane portion **762**, preferably formed of silicon nitride, silicon, carbon, or a polymer, preferably of thickness less than 100 nm and more preferably between 2-50 nm. One example of such a membrane support frame **760** and a thin membrane portion **762** is a model 4104SN-BA 30 nm silicon nitride membrane, commercially available from SPI Supplies, West Chester, Pa., USA.

Membrane support frame **760** is sealingly adhered to a membrane support **764**, which in turn sealingly mounted under an electrically insulative disc **766**. Insulative disc **766** is sealingly adhered to the underside of a flange portion **768** of a vacuum interface **770**, which is preferably formed with a sealing ring **772** to enhance sealing between flange portion **768** and insulative disc **766**.

As distinguished from the embodiment of FIG. 2A, here the membrane support frame **760** and the membrane support **764** may or may not be conductive and there is additionally provided a conductive layer **774** adhered to and underlying an membrane support frame **760** and membrane support **764**.

Turning now to FIG. 2E, it is seen that here, a vacuum retaining, beam permeable membrane comprises a peripheral membrane support frame **780**, typically formed of silicon or stainless steel, onto which is attached a relatively thin membrane portion **782**, preferably formed of silicon

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nitride, silicon, carbon, or a polymer, preferably of thickness less than 100 nm and more preferably between 2-50 nm. One example of such a membrane support frame **780** and a thin membrane portion **782** is a model 4104SN-BA 30 nm silicon nitride membrane, commercially available from SPI Sup-
plies, West Chester, Pa., USA.

Membrane support frame **780** is sealingly adhered to a membrane support **784**, which in turn sealingly mounted under an electrically insulative disc **786**. Insulative disc **786** is sealingly adhered to the underside of a flange portion **788** of a vacuum interface **790**, which is preferably formed with a sealing ring **792** to enhance sealing between flange portion **788** and insulative disc **786**.

As distinguished from the embodiment of FIG. 2D, here the membrane support frame **780** and the membrane support **784** are conductive and an insulative layer **794** is interposed between a conductive layer **795** and membrane support frame **780** and membrane support **784**. In this configuration, the conductive layer **795** need not be continuous and may be arranged, for example, in mutually electrically insulated quadrants **796**, **797**, **798** and **799** as shown. The insulative layer **794** is here seen to have a generally disc-like configuration.

Reference is now made to FIGS. 3A and 3B, which are simplified illustrations of two alternative sample holder electrode structures useful in the scanning electron microscopes of any of FIGS. 1A-2E.

Turning to FIG. 3A, it is seen that the sample holder comprises a sample holder base element **800**, typically including a circular base portion **802** and a circumferential cylindrical side wall **804**, integrally formed therewith. Base element **800** is preferably formed of an electrical conductor, such as aluminum or stainless steel, and is preferably mounted on a sample manipulator **806**.

Disposed on circular base **802** there is preferably provided an electrically insulative disc **808** onto which there is preferably disposed a disc **810**, which is formed of an electrically conductive material, typically aluminum or stainless steel. A sample **812** may be placed onto disc **810** so as to be impinged upon by at least one electron beam.

Turning to FIG. 3B, it is seen that here the sample holder comprises, similarly to the embodiment of FIG. 3A, a sample holder base element **820**, typically including a circular base portion **822** and a circumferential cylindrical side wall **824**, integrally formed therewith. Base element **820** is preferably formed of an electrical conductor, such as aluminum or stainless steel, and is preferably mounted on a sample manipulator **826**.

Disposed on circular base **822** there is preferably provided an electrically insulative disc **828** onto which there is preferably disposed a disc **830**, which is formed of an electrically conductive material, typically aluminum or stainless steel. A sample **832** may be placed onto disc **830** so as to be impinged upon by at least one electron beam.

As distinguished from the embodiment of FIG. 3A, in the embodiment of FIG. 3B there is provided an additional electrically conductive apertured disc **834** which is mounted on base element **820** and electrically insulated therefrom by means of an electrically insulative ring **836**.

Reference is now made to FIGS. 4A, 4B, 4C, 4D, 4E, 4F, 4G and 4H, which are simplified illustrations of various different electrical connections of various embodiments of scanning electron microscopes of the types shown hereinabove.

Turning to FIG. 4A, it is seen that the structure of the membrane holder **900** is similar to that shown in FIG. 2C and the structure of the sample holder **902** is similar to that

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shown in FIG. 3A. It is seen that the conductive disc **810** (FIG. 3A) operates as an electrode and is coupled to a voltage source **904**. It is also seen that apertured disc **754** (FIG. 2C) operates as an additional electrode as is coupled to ground and that apertured disc **744** operates as an output electrode and is coupled via a current amplifier **906** to detection circuitry (not shown).

Turning to FIG. 4B, it is seen that the structure of the membrane holder **910** is similar to that shown in FIG. 2C and the structure of the sample holder **912** is similar to that shown in FIG. 3A. It is seen that the conductive disc **810** (FIG. 3A) operates as an electrode and is coupled to a current source **914**. It is also seen that apertured disc **754** (FIG. 2C) operates as an additional electrode as is coupled to ground and that apertured disc **744** operates as an output electrode and is coupled via a current amplifier **916** to detection circuitry (not shown).

Turning to FIG. 4C, it is seen that the structure of the membrane holder **920** is similar to that shown in FIG. 2C and the structure of the sample holder **922** is similar to that shown in FIG. 3A. It is seen that the conductive disc **810** (FIG. 3A) is floating and is coupled neither to ground nor to a voltage or current source. It is also seen that apertured disc **754** (FIG. 2C) operates as an electrode as is coupled to ground and that apertured disc **744** operates as an output electrode and is coupled via a current amplifier **924** to detection circuitry (not shown).

Turning to FIG. 4D, it is seen that the structure of the membrane holder **930** is similar to that shown in FIG. 2C and the structure of the sample holder **932** is similar to that shown in FIG. 3A. It is seen that the apertured disc **744** (FIG. 2C) operates as an electrode and is coupled to a voltage source **934**. It is also seen that apertured disc **754** (FIG. 2C) operates as an additional electrode as is coupled to ground and that conductive disc **810** (FIG. 3A) operates as an output electrode and is coupled via a current amplifier **936** to detection circuitry (not shown).

Turning to FIG. 4E, it is seen that the structure of the membrane holder **940** is similar to that shown in FIG. 2C and the structure of the sample holder **942** is similar to that shown in FIG. 3A. It is seen that the apertured disc **744** (FIG. 2C) operates as an electrode and is coupled to a current source **944**. It is also seen that apertured disc **754** (FIG. 2C) operates as an additional electrode as is coupled to ground and that conductive disc **810** (FIG. 3A) operates as an output electrode and is coupled via a current amplifier **946** to detection circuitry (not shown).

Turning to FIG. 4F, it is seen that the structure of the membrane holder **950** is similar to that shown in FIG. 2C and the structure of the sample holder **952** is similar to that shown in FIG. 3A. It is seen that the apertured disc **744** (FIG. 2C) is floating and is coupled neither to ground nor to a voltage or current source. It is also seen that apertured disc **754** (FIG. 2C) operates as an electrode as is coupled to ground and that conductive disc **810** (FIG. 3A) operates as an output electrode and is coupled via a current amplifier **956** to detection circuitry (not shown).

Turning to FIG. 4G, it is seen that the structure of the membrane holder **960** is similar to that shown in FIG. 2C and the structure of the sample holder **962** is similar to that shown in FIG. 3A. It is seen that the conductive disc **810** (FIG. 3A) is floating and is coupled neither to ground nor to a voltage or current source. It is also seen that apertured disc **754** (FIG. 2C) operates as an electrode as is coupled to ground and that apertured disc **744** operates as an output electrode and is coupled via a Source Measuring Unit (SMU) **964** to detection circuitry (not shown).

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Turning to FIG. 4H, it is seen that the structure of the membrane holder 970 is similar to that shown in FIG. 2E and the structure of the sample holder 972 is similar to that shown in FIG. 3B. It is seen that the conductive disc 830 (FIG. 3B) operates as an electrode and is coupled via an SMU 974 to detection circuitry (not shown). It is also seen that apertured disc 834 also operates as an electrode and is coupled via an SMU 976 to detection circuitry (not shown). It is further seen that each of quadrants 796, 797, 798 and 799 (FIG. 2E) operates as an additional electrode and each is coupled via a separate SMU to detection circuitry (not shown). As seen in FIG. 4H, quadrant 796 is coupled to SMU 978 and quadrant 797 is coupled to SMU 980. Quadrants 798 and 799 are each coupled to a different SMU (not shown).

It will be appreciated by persons skilled in the art that the present invention is not limited to what has been particularly shown and described hereinabove. Rather the scope of the invention includes both combinations and subcombinations of the various features described hereinabove as well as modifications and variations thereof which would occur to persons skilled in the art upon reading the foregoing description and which are not in the prior art.

The invention claimed is:

1. A scanning electron microscope suitable for imaging samples in a non-vacuum environment, the scanning electron microscope comprising:

an electron source located within an enclosure maintained under vacuum;

an electron permeable membrane disposed at an opening of said enclosure separating an environment within said enclosure which is maintained under vacuum and an environment outside said enclosure which is not maintained under vacuum, said electron permeable membrane not being electrically grounded; and

at least one non-grounded electrode operative as an electron detector.

2. A scanning electron microscope suitable for imaging samples in a non-vacuum environment, the scanning electron microscope comprising:

an electron source located within an enclosure maintained under vacuum;

an electron permeable membrane disposed at an opening of said enclosure separating an environment within said enclosure which is maintained under vacuum and an environment outside said enclosure which is not maintained under vacuum; and

at least one non-grounded electrode operative as a support for said electron permeable membrane and functioning as part of an electron detector.

3. A scanning electron microscope suitable for imaging samples in a non-vacuum environment, the scanning electron microscope comprising:

an electron source located within an enclosure maintained under vacuum;

an electron permeable membrane disposed at an opening of said enclosure separating an environment within said enclosure which is maintained under vacuum and an environment outside said enclosure which is not maintained under vacuum;

a first non-grounded electrode operative as a support for said electron permeable membrane and functioning as part of an electron detector; and

a second non-grounded electrode operative associated with a sample support and functioning as part of an electron detector,

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a volume generally between said first and second electrodes generally being maintained at a positive pressure of less than 2 atmospheres.

4. A scanning electron microscope suitable for imaging samples in a non-vacuum environment, the scanning electron microscope comprising:

an electron source located within an enclosure maintained under vacuum;

an electron permeable membrane disposed at an opening of said enclosure separating an environment within said enclosure which is maintained under vacuum and an environment outside said enclosure which is not maintained under vacuum;

an ionized gas generator operative to provide an ionized gas in said environment outside said enclosure; and
at least one non-grounded electrode operative as an electron detector.

5. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 1 and also comprising an ionized gas generator operative to provide an ionized gas in said environment outside said enclosure.

6. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 4 and wherein said ionized gas forms a plasma.

7. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 4 and wherein said ionized gas generator comprises at least one of an RF coil and an ionizing light source.

8. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 4 and wherein said ionized gas generator comprises a humidifier.

9. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 4 and wherein said ionized gas comprises humidified helium gas.

10. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 9 and wherein said humidified helium gas has a relative humidity of at least 30% at 20° C.

11. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 9 and wherein said humidified helium gas has a relative humidity of at least 50% at 20° C.

12. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 9 and wherein said humidified helium gas has a relative humidity of at least 90% at 20° C.

13. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 1 and wherein said at least one non-grounded electrode forms part of a support for said electron permeable membrane.

14. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 1 and wherein said at least one non-grounded electrode is associated with a sample support.

15. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 1 and wherein said at least one non-grounded electrode is coupled to at least one of a current source and a voltage source.

16. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 1 and wherein said electron detector comprises at least one of a current amplifier and at least one Source Measuring Unit (SMU).

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17. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 2 and also comprising at least one additional non-grounded electrode associated with a sample support and functioning as part of an electron detector.

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18. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 17 and wherein at least one of said at least one non-grounded electrode and said at least one additional non-grounded electrode is coupled to at least one of a current source and a voltage source.

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19. A scanning electron microscope suitable for imaging samples in a non-vacuum environment according to claim 3 and wherein at least one of said first non-grounded electrode and said second non-grounded electrode is coupled to at least one of a current source and a voltage source.

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